

1 **Supplementary Information for**
2 **Robustness of Trion State in Gated Monolayer MoSe₂ under Pressure**

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I. Details of device fabrication, DFT calculation and QMC simulations

Device fabrication and photoluminescence measurements. Monolayer MoSe₂ and atomically-thin *h*-BN flakes were cleaved from their bulk crystals onto polydimethylsiloxane (PDMS) surfaces by mechanical exfoliation and then successively transferred onto a 300- μm -diameter diamond culet with prepatterned Ti/Au electrodes, forming an *h*-BN/MoSe₂/*h*-BN sandwiched structure. The prepatterned electrodes (Ti/Au, 5/15 nm) were evaporated with a shadow mask. The thickness of monolayer MoSe₂ is identified by the optical image and PL spectrum. The whole process of sample preparation was completed in ambient atmosphere. The Pt electrodes with a thickness of 4 μm were then placed at the edge of the Ti/Au electrodes on the diamond culet to ensure good electrical contact under high pressure. Silicon oil was used as the transmitting pressure medium to provide a hydrostatic pressure. The absolute value of the applied pressure was calibrated by the peak position of ruby fluorescence at room temperature [1]. The PL measurements were performed using a confocal Raman system (WITec Alpha 300) with a laser wavelength of 532 nm. The laser power was set as 1 mW to avoid sample heating for both room-temperature and low-temperature PL measurements. The laser beam was focused on the sample with a long working distance $\times 50$ objective lens. Low-temperature PL measurements were performed with DAC installed in a microscopy cryostat. The gate bias was applied by a Keithley 2400. After all the low-temperature measurements were performed, the sample was warmed to room temperature to apply a higher pressure through DAC. All the PL spectra were fitted by multiple Voigt functions to clarify the peak energies, linewidths and integrated PL peak intensities.

Density functional theory calculations. The DFT calculations were performed with the Vienna *ab initio* simulation package (VASP) [2] using the projector augmented wave method (PAW) [3, 4]. The plane-wave energy cutoff was 550 eV, and the convergence criteria of the forces was set as 10^{-3} eV/Å. The Brillouin zones were sampled by $15 \times 15 \times 4$ and $15 \times 15 \times 1$ Monkhorst-Pack grids for the bulk structures and the slab models, respectively. The exchange-correlation functional was chosen as the Perdew–Burke–Ernzerhof (PBE)-type generalized gradient approximation (GGA) [5]. The van der Waals correction [6, 7] was considered within the calculations. Moreover, spin-orbit coupling was included in the electronic structure calculations. The lattice constants *a* (and *b*) and *c* of the MoSe₂ bulk structure were 3.332 Å and 13.17 Å, respectively, after full relaxation, which were consistent with previous studies [8, 9]. The influence of hydrostatic pressures was simulated by the application of geometric optimization on the MoSe₂ bulk structure under zero pressure, where a similar method was employed in a previous study [10]. After that, monolayer MoSe₂ models were built directly for further calculations, where a vacuum layer of 20 Å was added in the vertical direction of each slab structure.

The calculations with the GGA-PBE functional underestimated the bandgap at the K (and K') points for monolayer MoSe₂ while correctly describing the evolution of the Λ –K crossover of the conduction band with increasing pressure. Thus, we used the HSE06 hybrid functional [11, 12] to correct the band gap of monolayer MoSe₂. Under zero pressure, the calculated result was 1.99 eV for the direct band gap at the K point, which was very close to that from G_0W_0 calculations [13] (2.08 eV). However, the HSE06 functional failed to describe the Λ –K crossover of conduction bands with increasing pressure. In our QMC simulations, we used the direct bandgap from the HSE06 functional for the monolayer under zero pressure (1.99 eV), while the change in bandgap with respect to

77 increasing pressure (28 meV/GPa) and the effective masses were obtained by using the GGA-PBE
78 functional.

79 Quantum Monte Carlo simulations for excitons and trions. To calculate the binding energies of the
80 exciton (trion), we employ an effective-mass model for two (three) charged point-like particles in
81 2D. Each particle is assumed to have a parabolic band of effective mass m_i^* . By separating out the
82 center-of-mass motion [14-16], we recast the internal two-body dynamics of the excitons in terms of
83 their relative coordinates using a one-particle ($i = 1$) effective-mass Hamiltonian, which has the form

$$84 \quad H_{\text{exciton}} = -\frac{\hbar^2}{2\mu}\Delta + V_{2\text{D}}(\rho), \quad (1)$$

85 and the internal three-body dynamics of the trion using a two-particle ($i = 1, 2$) effective-mass
86 Hamiltonian, which has the form

$$87 \quad H_{\text{trion}} = -\frac{\hbar^2}{2\mu}\Delta_1 - \frac{\hbar^2}{2\mu}\Delta_2 - \frac{\hbar^2}{M}\nabla_1 \cdot \nabla_2 \quad (2)$$

$$+ V_{2\text{D}}(\rho_1) + V_{2\text{D}}(\rho_2) - V_{2\text{D}}(|\rho_1 - \rho_2|),$$

88 where $\mu = \frac{1}{m_e^{-1} + m_h^{-1}}$ is the reduced effective mass of the electron-hole pair, $M = 2m_e + m_h$ is the
89 total mass of trion, Δ_i and ∇_i are, respectively, the Laplacian and gradient operators acting on
90 functions of ρ_i . For excitons, the i label is implicit (see Fig. 4c). For trions, relative coordinates, ρ_i ,
91 are defined as the spatial relative vectors between identical charges ($i = 1, 2$) and nonidentical
92 charges (see Fig. 4d). For the trion, the hole has the nonidentical charge, while the electrons have
93 identical charges. $V_{2\text{D}}$ is the effective screened Coulomb potential energy of the Rytova-Keldysh
94 form [17-20],

$$95 \quad V_{2\text{D}}(\rho) = -\frac{\pi e^2}{2\rho_0 \epsilon^*} \left[H_0\left(\frac{\rho}{\rho_0}\right) - Y_0\left(\frac{\rho}{\rho_0}\right) \right], \quad (3)$$

96 where H_0 and Y_0 are, respectively, the Struve and Bessel functions of the second kind, e is the
97 (positive) elementary charge, ϵ^* is the effective dielectric constant that is the average of the dielectric
98 constants of the media above (ϵ_{above}) and below (ϵ_{below}) the 2D monolayer and ρ_0 is the effective
99 screening radius. Since ρ_0 is related to the finite thickness of the 2D monolayer, d , and its in-plane
100 dielectric constant, $\epsilon_{2\text{D}}$, by $\rho_0 = \frac{d\epsilon_{2\text{D}}}{\epsilon_{\text{above}} + \epsilon_{\text{below}}}$, setting ρ_0 to 4 times the Bohr radius of hydrogen is

101 equivalent to setting $\epsilon_{2\text{D}}$ to 3.11 if we approximate the thickness of the 2D monolayer to 8.3 Å. The
102 third term on the RHS of Eq. (2) that is $\propto \nabla_1 \cdot \nabla_2$ is the mass-polarization term, also known as the
103 Hughes–Eckart term [21]. If we were to compare Eq. (2) with the Hamiltonian for the H^- ion, the
104 Hughes–Eckart term corrects for the finite mass, M , of the nonidentical charge within the effective-
105 mass approximation. In these effective Hamiltonians, we use effective masses obtained from DFT at
106 different pressures. For the bandgap at the K point in monolayer MoSe_2 under no pressure, we used
107 the HSE06 hybrid functional to correct the bandgap.

108 We use the variational QMC to obtain the wavefunction and eigenvalues of excitons and trions. Our
109 QMC calculations use 500 random walkers and step lengths that give an acceptance ratio of 0.5. Each
110 walker makes a total of 2.0×10^5 Monte Carlo moves and 5000 thermalization steps. Next, we define
111 our trial exciton and trion wavefunctions. For the exciton, energy minimization is carried out using
112 the 2D hydrogenic $1s$ state as the trial wavefunction, $\phi_{\text{exciton}}^{1s}(\rho) = A \exp(-2\alpha\rho)$, where A is a
113 normalization constant and α is the variational parameter; for the trion, the product of the $1s$ exciton
114 wavefunction is used as the trial wavefunction, $\phi_{\text{trion}}^{1s}(\boldsymbol{\rho}_1, \boldsymbol{\rho}_2) = B \exp(-2\alpha\rho_1) \exp(-2\alpha\rho_2)$,
115 where B is a normalization constant and $\boldsymbol{\rho}_i$ is the electron–hole relative coordinates. The latter
116 wavefunction is reminiscent of the 1^1S ground state of H^- and He , which is spin anti-symmetric and
117 has the orbital character of $1s^2$ (or $1s \otimes 1s$). In this choice of this trial wavefunction, there is no
118 correlation between $\boldsymbol{\rho}_1$ and $\boldsymbol{\rho}_2$. Correlations are subsequently added via the multiplication of the
119 mass-polarization factor, $(1 + c|\boldsymbol{\rho}_1 - \boldsymbol{\rho}_2|)$, to the abovementioned $\phi_{\text{trion}}(\boldsymbol{\rho}_1, \boldsymbol{\rho}_2)$.

120 The effective screened Coulomb interaction inside the 2D monolayer is calculated using the Rytova–
121 Keldysh model [17, 18], wherein the experimental h -BN dielectric constant [22] of 6.07 is used as
122 the dielectric constant of the media above (ϵ_{above}) and below (ϵ_{below}) the 2D monolayer. In the
123 Rytova–Keldysh model, the effective screening radius, ρ_0 , defines the length scale at which the
124 Coulomb potential, $V(\rho)$, crosses over from being 2D-like at a short range (for $\rho < \rho_0$), to being 3D-
125 like at a long range (for $\rho > \rho_0$). In this work, we use ρ_0 as our only fitting parameter, setting it to ρ_0
126 $= 2.1 \text{ \AA}$, which is 4 times the Bohr radius of hydrogen, to fit the calculated $E_{\text{b}}^{\text{exciton}}$ at 0.22 GPa.
127 Without further fitting other parameters, we calculate $E_{\text{b}}^{\text{exciton}}$ for the remaining pressure range and
128 $E_{\text{b}}^{\text{trion}}$ at all pressures. Note that in our work we defined the trion binding energy as $E_{\text{b}}^{\text{trion}}$, i.e.,
129 $E_{\text{b}}^{\text{trion}} = E_{\text{exciton}} - E_{\text{trion}}$ following a long practice used in the field of low-dimensional
130 semiconductors [23, 24]. The trion state is regarded as a bound state of an exciton and an electron
131 and thus the “trion binding energy” is regarded as the energy difference of the exciton and trion state.
132 In our calculations, we considered the increase of the bandgap as pressure increases and observed the
133 related increase in exciton binding energy due to the enlargement of the effective masses of electrons
134 and holes. But the energy variation of exciton peak is smaller than the change of bandgap (see Fig. 4
135 in the main text). Such an observation is analogous to the *cancellation effect* reported previously [25-
136 28], in which the increase in bandgap is partly compensated by the increase in exciton binding energy
137 and thus the absolute energy level of the exciton remains relatively constant. In our calculations, the
138 observed compensation is smaller than that obtained by varying dielectric environments, as our
139 model does not consider the decrease in dielectric screening (which will increase the exciton binding
140 energy) as the bandgap increases as pressure increases [25].

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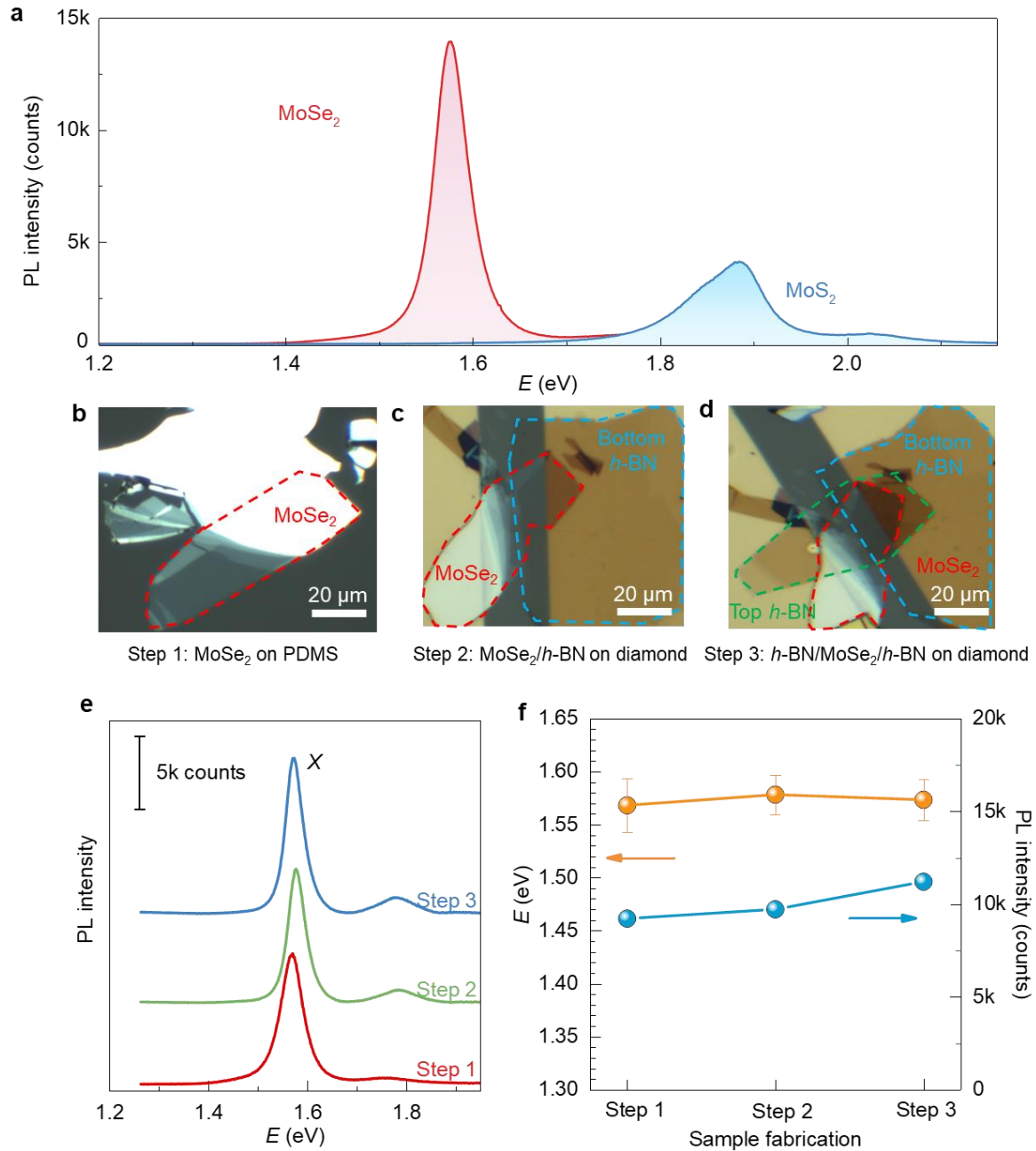
142 II. Fabrication of *h*BN-gated monolayer MoSe₂ devices in a DAC cell

143 We selected MoSe₂ as an example for studying excitonic physics under pressure based on the results
144 of comparing the photoluminescence (PL) properties of four commonly-used monolayer transition
145 metal dichalcogenides (TMDCs), including MoS₂, MoSe₂, WS₂, and WSe₂. For the PL spectra of
146 monolayer MoS₂ and MoSe₂ on the diamond culet (Supplementary Fig. 1a), it is evident that the PL
147 emission peak of MoSe₂ has both stronger intensity and narrower linewidth than those of MoS₂,
148 suggesting a higher quantum yield of MoSe₂. We did not use WS₂ and WSe₂ due to the complexity
149 in their excitonic states reflected by their low-temperature PL emissions. Therefore, we chose
150 monolayer MoSe₂ as the target material for probing and studying excitonic states under pressure via
151 our *gating-under-pressure* technique.

152 To investigate the excitonic physics of MoSe₂ under pressure, we fabricated a monolayer MoSe₂
153 device using *h*-BN as a dielectric material for the back gate in the diamond anvil cell (DAC) setup.
154 There are three main steps in the fabrication process of our device, as illustrated in Supplementary
155 Fig. 1b–d.

156 **Step 1: MoSe₂ on PDMS.** The monolayer MoSe₂ was mechanically exfoliated onto PDMS
157 (polydimethylsiloxane) and then selected via its optical contrast (Supplementary Fig. 1b) and PL
158 spectrum. Thin *h*-BN flakes were chosen according to their optical contrast only. **Step 2: MoSe₂/*h*-**
159 **BN on diamond.** In the dry transfer process, the *h*-BN thin flake was transferred onto a 300- μ m-
160 diameter diamond culet with prepatterned electrodes, partially covering the right electrode and not
161 physically contacting the left electrode. The distance between the prepatterned Ti/Au electrodes was
162 approximately 20 μ m, and the thickness of Ti/Au was 5/15 nm. Subsequently, the monolayer MoSe₂
163 (connected with a thick MoSe₂ flake) was transferred on top of the thin *h*-BN flake and isolated to
164 the right electrode with *h*-BN as the dielectric layer, forming a vertical MoSe₂/*h*-BN/Au sandwiched
165 structure (Supplementary Fig. 1c). Simultaneously, the thick part of this MoSe₂ flake was electrically
166 contacted to the left electrode, which served as the source electrode. **Step 3: *h*-BN/MoSe₂/*h*-BN on**
167 **diamond.** Another *h*-BN flake was transferred to completely cover monolayer MoSe₂
168 (Supplementary Fig. 1d). This *h*-BN flake can protect monolayer MoSe₂ from degradation and
169 effectively improve the data quality when immersed in the pressure transmitting medium. Here, we
170 used silicon oil as the pressure transmitting medium to provide hydrostatic pressure. **Finally,** we
171 sealed the DAC after dropping the silicon oil and connecting the electrodes to the outside of the DAC.

172 In each process, the PL spectrum of MoSe₂ (Supplementary Fig. 1e) and the corresponding PL
173 emission energy and peak intensity of the exciton (Supplementary Fig. 1f) are obtained. On the one
174 hand, the exciton emission energy shows a slight redshift after Step 3 (encapsulating MoSe₂ with *h*-
175 BN), which is attributed to the reduction of both the bandgap and exciton binding energy due to the
176 increased dielectric screening of MoSe₂. On the other hand, the PL intensity of the exciton peak
177 increases after Step 3. This enhancement can be attributed to the optical interference effect in the
178 multi-layered substrate, which was recently confirmed in monolayer WS₂ within a WS₂/*h*-BN/Au
179 structure [29].



180

181 **Supplementary Figure 1. Fabrication process of gated monolayer MoSe₂ device in DAC.** **a**, Comparison
 182 of the PL spectra of monolayer MoSe₂ (red curve) and MoS₂ (blue curve) on a diamond culet. The PL
 183 measurements were performed under the same conditions (the laser power was 1 mW, and the integrated time
 184 was 20 seconds) at room temperature. **b–d**, Optical image of **b**, MoSe₂ on PDMS in step 1, **c**, h-BN/MoSe₂
 185 heterostructure on diamond in step 2, and **d**, h-BN/MoSe₂/h-BN heterostructure on diamond in step 3. The
 186 scale bar is 20 μ m. **e**, PL spectrum obtained during the process of device fabrication of **b–d**. **f**, The exciton
 187 emission energy and PL intensity evolution during the device fabrication process. The error bar is the full width
 188 at half maximum (FWHM) of the PL peak.

189

190 III. Confirmation of the effective lattice compression of monolayer TMDCs under pressure

191 To confirm whether the pressure inside DAC is hydrostatic, we checked the ruby PL peak at each
192 pressure point (Supplementary Fig. 2a). Normally, the line width of the ruby peak would become
193 broader when the pressure becomes nonhydrostatic. While in our case, the line width of our ruby
194 peaks shows almost no change with increasing pressure up to 4.2 GPa (Supplementary Fig. 2b),
195 indicating that the pressure can be considered hydrostatic based on the silicon oil pressure medium.
196 More importantly, such hydrostatic pressure is rather uniform. Supplementary Fig. 2c-d shows the
197 pressure as a function of distance from the center of DAC under a pressure of 2.5 GPa. One can see
198 the pressure fluctuation is as small as 0.2 GPa across a distance of 50 μm .

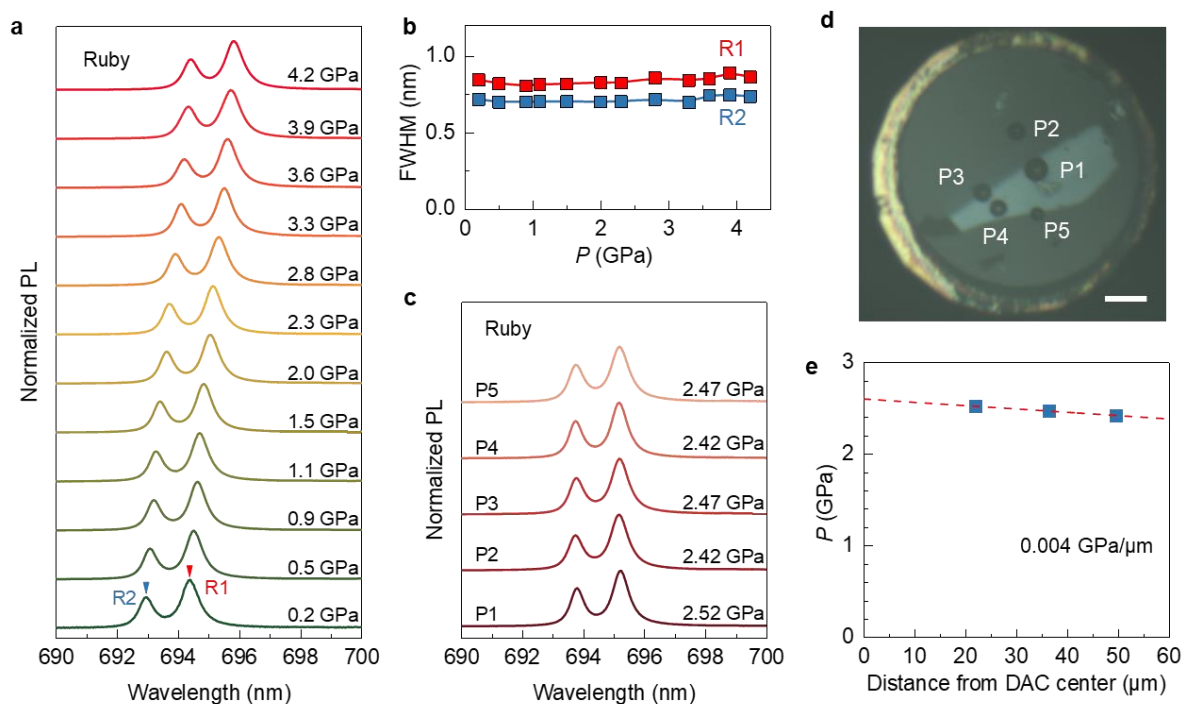
199 We performed high-pressure Raman measurements on monolayer TMDCs within DAC to confirm
200 that the pressure applied on monolayer samples is similar to those scenarios in bulk-type samples and
201 to verify that the lattice is effectively compressed. At ambient pressure, we focus on the two unique
202 Raman modes in monolayer MoS_2 (Supplementary Fig. 3a): the A_{1g} mode located at 404 cm^{-1}
203 corresponding to the out-of-plane vibrations and the E_{2g}^1 mode located at 384 cm^{-1} corresponding to
204 the in-plane vibrations [30]. Based on the fact that the compression of the lattice normally causes the
205 stiffening of the Raman modes in MoS_2 samples [31], we confirm the applied pressure in our
206 monolayer samples by comparing the Raman modes with two other different TMDC samples: bulk
207 samples under hydrostatic pressure and ultrathin samples under uniaxial strain. Note that here we
208 chose MoS_2 instead of MoSe_2 as our example because the signal of the in-plane vibration E_{2g}^1 mode
209 in MoSe_2 is technically too weak to be detected since there is no resonance Raman effect [32] under
210 the excitation of a 532 nm laser, and only the out-of-plane A_{1g} mode can be clearly observed.
211 Therefore, we do not have any opportunity to study the pressure effect on the in-plane compression
212 in monolayer MoSe_2 due to its undetectable in-plane E_{2g}^1 mode. Fortunately, for MoS_2 monolayers,
213 the signals for both the E_{2g}^1 and A_{1g} modes are strong enough for a reliable comparison
214 (Supplementary Fig. 3a).

215 First, for bulk MoS_2 under hydrostatic pressure, in which the applied pressure is widely accepted to
216 be isotropic [31], both the A_{1g} and E_{2g}^1 modes of the compressed MoS_2 lattice show an obvious
217 blueshift with increasing pressure. Such Raman blueshifts are directly associated with lattice
218 compression in bulk MoS_2 and are reported to shift at a rate of $3.7\text{ cm}^{-1}/\text{GPa}$ for the A_{1g} mode and
219 $1.8\text{ cm}^{-1}/\text{GPa}$ for the E_{2g}^1 mode in bulk MoS_2 [31]. The ratio between the changing rates of the A_{1g}
220 mode and E_{2g}^1 mode with pressure in bulk MoS_2 is close to 2, which is almost the same as the value
221 in our monolayer case (Supplementary Fig. 3b). More importantly, the linear behaviour of all the
222 modes in our monolayer case directly indicate the absence of notable non-hydrostatic stress
223 components [33]. Note that in Supplementary Fig. 3c, we also provide the Raman shifts of the out-
224 of-plane vibration A_{1g} mode in monolayer MoSe_2 under different pressures. One can see that, similar
225 to monolayer MoS_2 , the Raman shifts of the out-of-plane vibration A_{1g} mode in monolayer MoSe_2
226 shows a linear blueshift with increasing pressure. These facts indicate that the pressure is effectively
227 applied to our monolayer materials and that the lattice of the monolayer structure is compressed.

228 Second, to confirm that the pressure is along both in-plane and out-of-plane directions in our case,
229 we compare our results under pressure with those cases under biaxial tensile strain [34] or uniaxial
230 tensile strain (Supplementary Fig. 3d). For those cases under biaxial/uniaxial tensile strain, the
231 sample is stretched a lot along in-plane directions, while compressed only a little along out-of-plane
232 directions, resulting in the remarkable redshift for in-plane E_{2g}^1 mode while almost no shift for out-
233 of-plane A_{1g} modes [35]. However, our monolayer MoS_2 , with a pressure-induced compression of
234 the in-plane lattice constant, shows a remarkable blueshift for the E_{2g}^1 mode rather than a redshift.
235 This fact directly excludes the existence of in-plane lattice expansion in DAC.

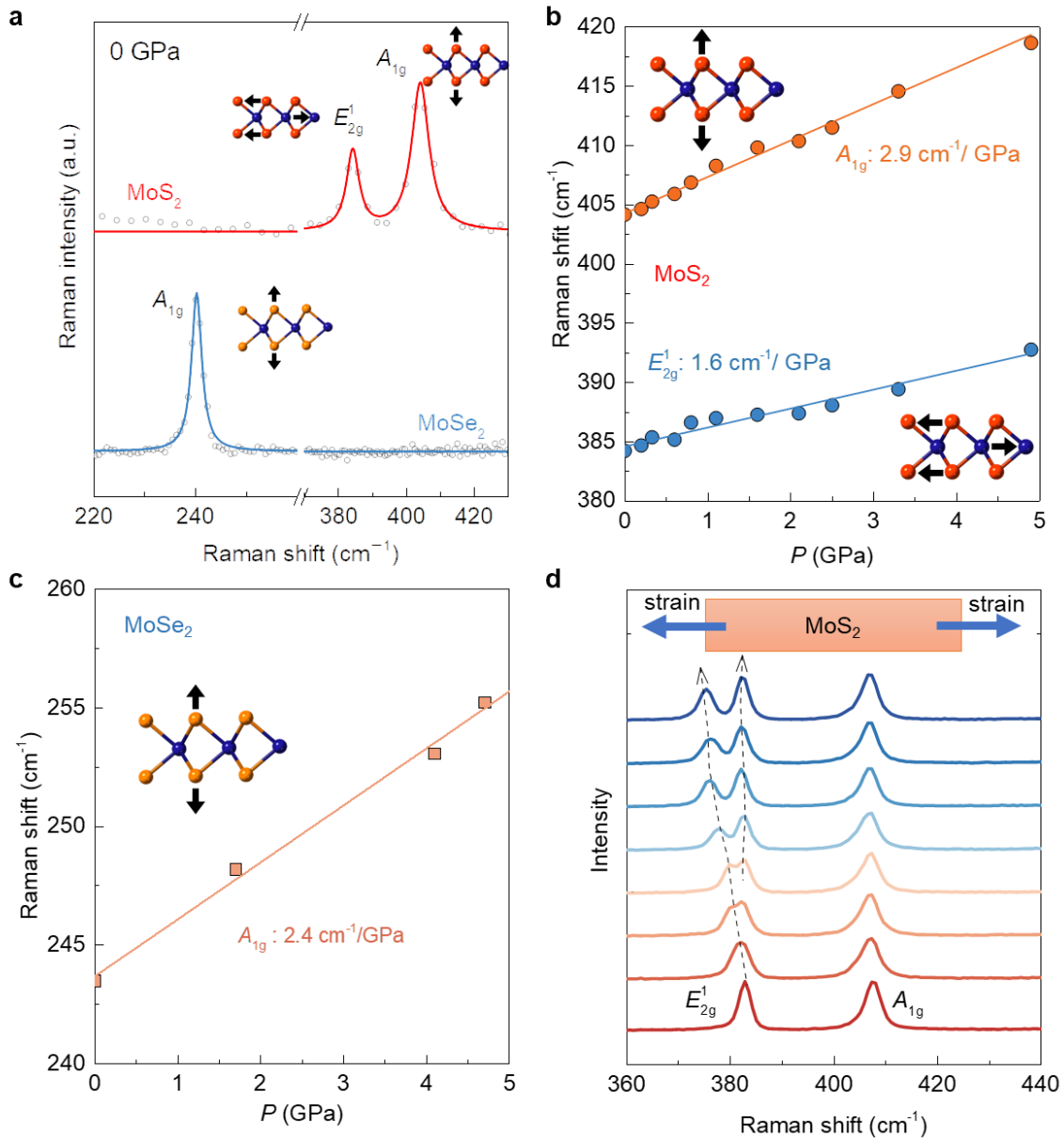
236 Based on the comparisons between our results and those in the literature, we have confirmed that our

237 monolayer samples undergo a quasi-hydrostatic pressure (not the type of strictly-hydrostatic pressure
 238 but indeed being the 3D compressed pressure in three dimensions).



239
 240 **Supplementary Figure 2. Ruby photoluminescence for determining pressure.** **a**, PL spectra of ruby under
 241 different pressures for the monolayer MoSe₂ sample in the main text. The arrows highlight the R1 and R2 peaks.
 242 **b**, The full width at half maximum (FWHM) of the R1 and R2 peaks as a function of pressure. **c**, Normalized
 243 PL spectra of ruby at different positions inside the DAC at a pressure of approximately 2.5 GPa **d**, The
 244 corresponding optical image of ruby distribution inside the DAC. The scale bar is 50 μm. **e**, Pressure values in
 245 the DAC as a function of the distance from the DAC center for a specific case.

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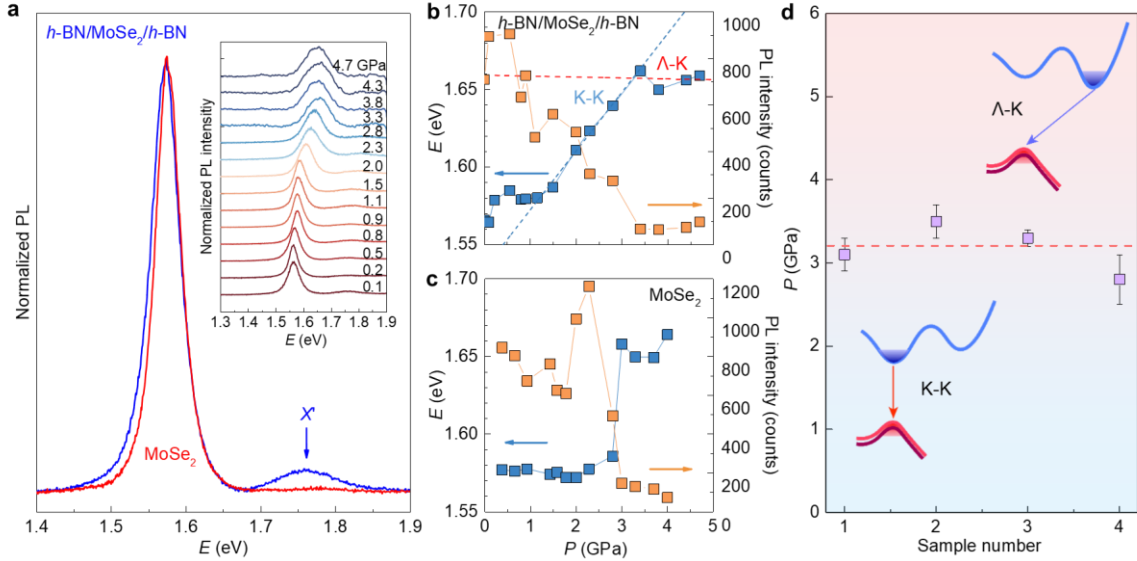
Supplementary Figure 3. Raman spectra of monolayer MoS₂ under compression (pressure) and tensile strain at room temperature. **a**, Comparison of Raman spectra of monolayer MoS₂ and MoSe₂ at ambient pressure. Inset: schematic figures of the out-of-plane A_{1g} and in-plane E_{2g}^1 vibration modes. The blue and red balls represent the Mo and S (or Se) atoms. The black arrows represent the vibration of the corresponding atom. **b**, Raman shifts of the A_{1g} (orange circles) and E_{2g}^1 (blue circles) modes as a function of pressure in monolayer MoS₂. The solid lines are linear fits. Inset: schematic figures of out-of-plane A_{1g} and in-plane E_{2g}^1 vibration modes. **c**, Raman shifts of the A_{1g} modes as a function of pressure in monolayer MoSe₂. The solid lines are linear fits. Inset: schematic figures of out-of-plane A_{1g} vibration modes. **d**, Raman spectra of few-layer MoS₂ with increasing uniaxial strain up to 2%. Inset: schematic of uniaxial strain applied on few-layer MoS₂. The E_{2g}^1 peak splits into two subpeaks as the degeneracy is lifted owing to the lattice symmetry breaking of MoS₂ under strain [36] and the central part of the two split peaks shows a clear redshift with increasing strain, while A_{1g} shows no measurable shift.

IV. Evidence for the Λ -K crossover and direct-to-indirect optical transition in pressurized monolayer MoSe₂

To clearly demonstrate the improved data quality with *h*-BN encapsulation, we directly compare the normalized PL spectra of MoSe₂ with and without *h*-BN encapsulation, as shown in Supplementary Fig. 4a. Only in the case of encapsulated MoSe₂ can we observe a small PL peak at higher energy than the exciton (*X*), which is commonly referred to as the *X'* exciton. These excitons are caused by the spin-split valence band at the K points due to the strong spin-orbit coupling of monolayer MoSe₂. Based on the enhanced PL intensity (Supplementary Fig. 1f) and detectable *X* and *X'* excitons at room temperature, we demonstrate that the *h*BN-encapsulated samples can serve as a better platform for studying the optical properties of TMDCs under pressure.

To determine the pressure evolution of the band structure of monolayer MoSe₂, we analyzed the PL spectra under various pressures and discussed the consequent change in excitonic states. The inset of Supplementary Fig. 4a shows the normalized PL spectra of *h*BN-encapsulated MoSe₂ under pressures ranging from 0.1 to 4.7 GPa (original data of Fig. 1c in the main text). Supplementary Fig. 4b shows the emission energy and PL intensity of the exciton peak as a function of pressure. From 0.1 to 3.0 GPa, the exciton emission energy increases linearly with increasing pressure, which is caused by the pressure-induced bandgap increasing at the K point. However, at pressures higher than 3.0 GPa, the exciton emission energy exhibits a redshift trend with increasing pressure, which may be caused by the Λ -K crossover transition with the emission process transiting from the direct to indirect optical transition, corresponding to the lowering of the conduction band minimum at the Λ point. The PL intensity decreases with increasing pressure to 3.0 GPa and becomes undetectable with further increased pressure. We deduce that such changes in exciton emission energy and peak intensity correspond to the Λ -K crossover in the band structure of monolayer MoSe₂, as mentioned in the main text.

To further verify the reproducibility of the Λ -K crossover and the resulting direct-to-indirect bandgap transition in monolayer MoSe₂, we fabricated several MoSe₂ devices with and without *h*-BN capping layers in the DAC setup and measured their room-temperature PL spectra at various pressures. Supplementary Figure 4c shows the emission energy and PL intensity of the exciton peak as a function of pressure for a MoSe₂ sample without *h*-BN encapsulation. The exciton emission energy blueshifts with pressure up to 3.0 GPa and then starts to show a redshift trend. The PL intensity decreases to a relatively low level above 3.0 GPa. These pressure-dependent behaviors are similar to those of the sample with the capping layer of *h*-BN (Supplementary Fig. 4b). We determined the critical pressure of the Λ -K crossover by using the abrupt decrease in the exciton peak intensity as a simple criterion. Supplementary Figure 4d shows the critical pressures obtained in four different monolayer MoSe₂ samples, which are similar and yield an average value of approximately 3.2 GPa.

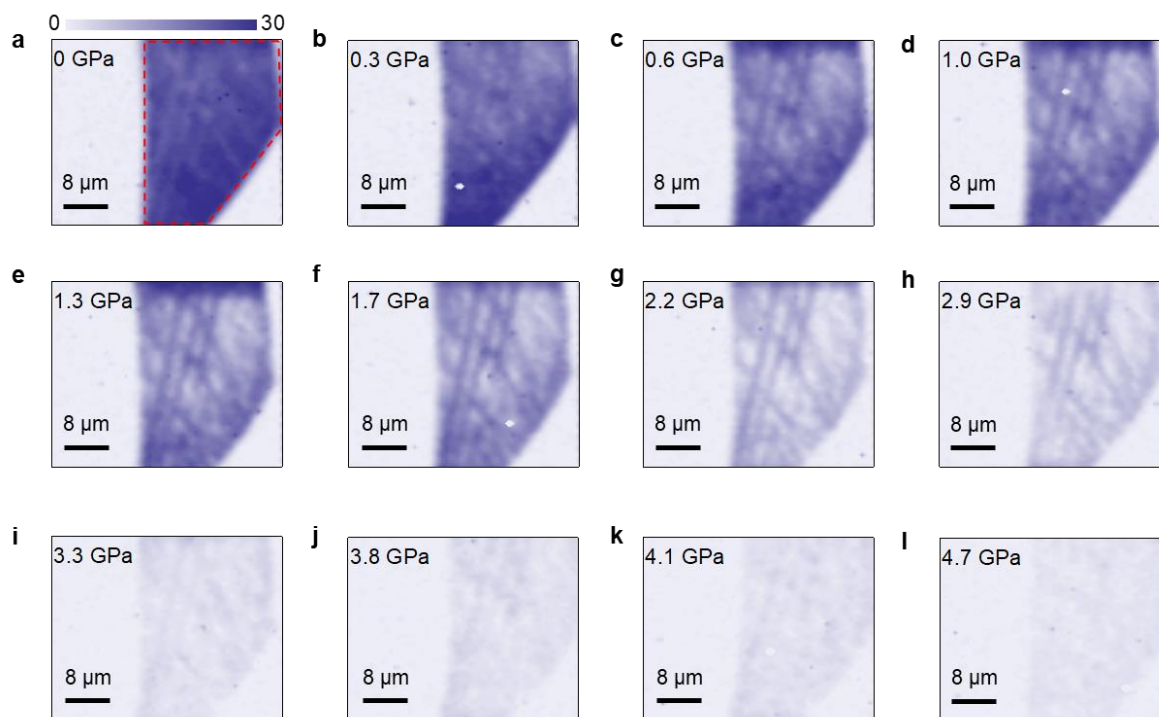


296
 297 **Supplementary Figure 4. Pressure-dependent PL spectra of monolayer MoSe₂.** **a**, Comparison of room-
 298 temperature PL spectra of monolayer MoSe₂ with and without *h*-BN encapsulation in DAC. The blue arrow
 299 points to the peak corresponding to the X' exciton. Inset: Room-temperature PL spectra of monolayer MoSe₂
 300 with an *h*-BN capping layer under pressure from 0.1 GPa to 4.7 GPa. The PL spectra are normalized to the
 301 maximum PL intensity and shifted on the Y-axis for better visualization. **b**, Exciton emission energy (blue
 302 square) and PL intensity (orange square) as a function of pressure with *h*-BN capping layers. **c**, Emission energy
 303 (blue square) and PL intensity (orange square) of exciton as a function of pressure of MoSe₂ without an *h*-BN
 304 capping layer. **d**, Critical pressure of the Λ -K crossover in four individual monolayer MoSe₂. The error bar
 305 represents the uncertainty of the critical pressure. The horizontal dashed line highlights the critical pressure of
 306 3.2 GPa. Inset: schematic illustration of the K-K direct transition (bottom) and Λ -K indirect transition (top).

307 Supplementary Figure 5 presents the spatial distribution of the exciton peak intensity at various
 308 pressures, demonstrating three important features: i) the homogeneity of the applied pressure in the
 309 sample, ii) the details of the pressure distribution of the sample during compression, and iii) a more
 310 intuitive process of pressure-induced Λ -K crossover in MoSe₂. On the one hand, the PL intensities
 311 in the sample are rather uniform across a wide range of pressures, implying that the entire sample
 312 undergoes a uniform external pressure field in the compression process. On the other hand, the PL
 313 intensities of the exciton peak drop rapidly with pressure and approach the background level at 3.3
 314 GPa. As discussed above, this quenching of PL with increasing pressure corresponds to the Λ -K
 315 crossover and the direct-to-indirect bandgap transition therein.

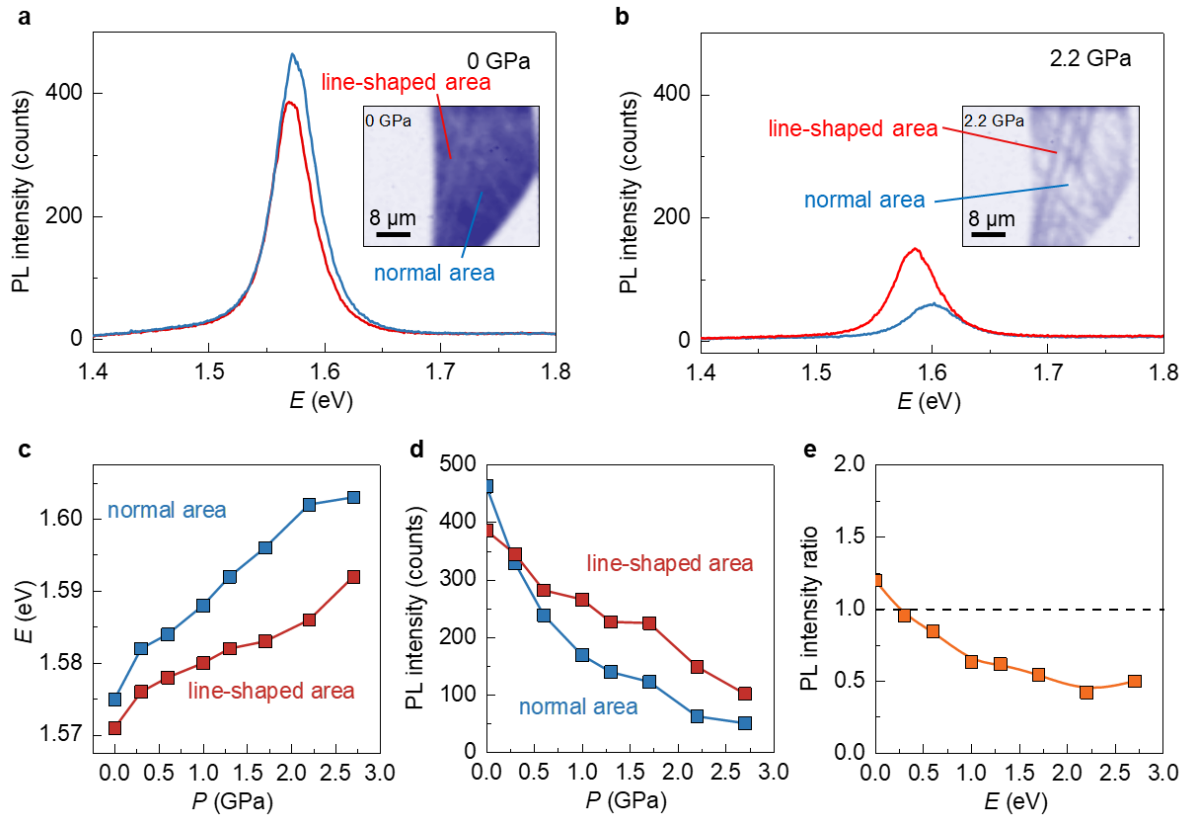
316 Interestingly, at 0 GPa, one can see several fine lines in the PL intensity mapping across the sample
 317 (denoted as the “line-shaped area”), in which the PL intensity is slightly smaller than the values in
 318 “normal area”. However, the several fine lines across the sample become clearer under pressure and
 319 the PL intensity of these “line-shaped area” becomes larger than the “normal area”. To figure out the
 320 origin of such PL intensity reversal between these “line-shaped area” and “normal area”, we compare
 321 the corresponding PL spectra at the “line-shaped area” and the “normal area” (Supplementary Fig.
 322 6). One can see at 0 GPa the PL peak energy is smaller at the “line-shaped area” compared to the
 323 “normal area” (Supplementary Fig. 6a), indicating that the sample therein is under a small tensile
 324 strain. Such a strain might increase the non-radiation recombination of excitons and decrease the PL
 325 intensity. While, once we applied an external pressure (Supplementary Fig. 6b), the evolution of the

326 exciton energy with the applied pressure in the “line-shaped area” and “normal area” can be different
 327 and the MoSe₂ in these two areas shows different sensitivities to the pressure due to the residual
 328 lattice strain in the “line-shaped area” (Supplementary Fig. 6c). Thus, the PL peak intensity in the
 329 “line-shaped area” decreases slower with pressure than that in the “normal area” (Supplementary Fig.
 330 6d) and shows the PL intensity inverse, which can be verified by an intensity crossover at about 0.3
 331 GPa (Supplementary Fig. 6e). Since the residual strain in transferred vdW samples is common and
 332 can be easily controlled, we believe that such non-uniformity in PL mapping can be avoided by
 333 annealing the initial sample or optimizing the sample transfer procedure.



334

335 **Supplementary Figure 5. PL mapping of the integrated intensity of the X peak in pressurized MoSe₂ at**
 336 **different pressures. a–l,** Images are obtained at a fixed temperature of 300 K with different pressures. The
 337 scale bar is 8 μm. The color bar indicates the exciton peak integrated intensity. The red dashed line highlights
 338 the region of monolayer MoSe₂. Note that data at 0, 1.3, 2.2, and 3.3 GPa have already been given in Fig. 1e
 339 in the main text.



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Supplementary Figure 6. A detailed comparison of PL emissions at different spatial positions in pressurized MoSe₂ samples. a, The PL spectra at the “line-shaped area” (red) and the “normal area” (blue) at 0 GPa. The insets highlight the region of “line-shaped area” and the “normal area”. **b**, The PL spectra at the “line-shaped area” (red) and the “normal area” (blue) at 2.2 GPa. **c**, Exciton emission energy of monolayer MoSe₂ as a function of pressure. The red and blue squares represent data obtained from “line-shaped area” and “normal area”. **d**, Exciton PL intensity of monolayer MoSe₂ as a function of pressure. The red and blue squares represent data obtained from “line-shaped area” and “normal area”. **e**, The PL intensity ratio between “normal area” and “line-shaped area” as a function of pressure.

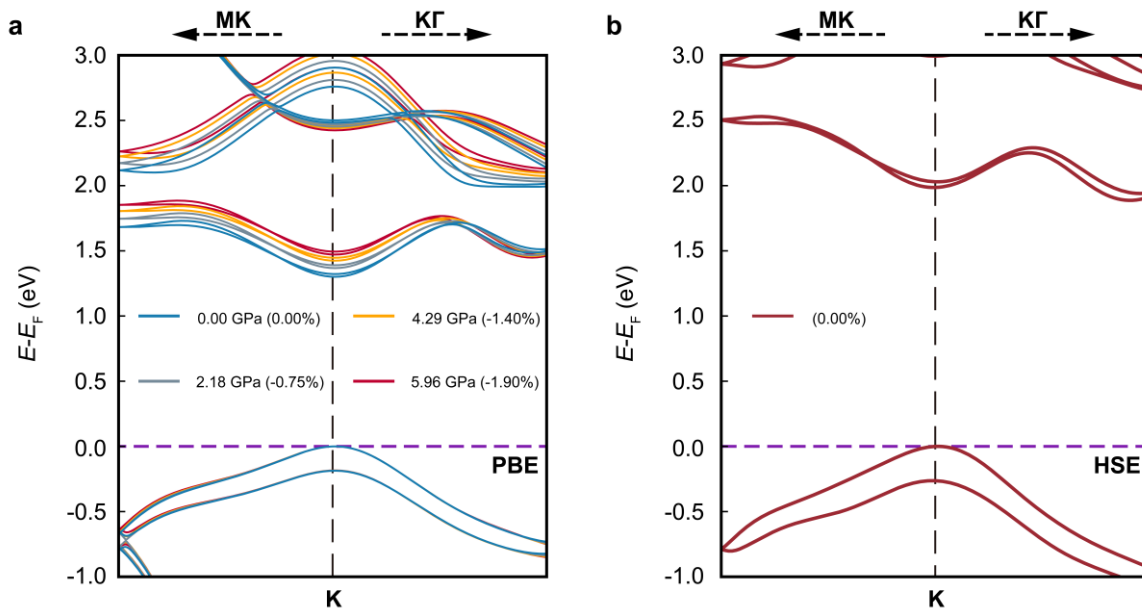
V. Pressure-dependent band structure calculations in monolayer MoSe₂

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351 To understand the blueshift of exciton and trion states with increasing pressure, we performed DFT
352 calculations to obtain the pressure-dependent electronic structures of monolayer MoSe₂. These
353 calculated results within the GGA-PBE functional are shown in Supplementary Fig. 7a. We found
354 that the GGA-PBE functional could correctly describe the Λ -K crossover of the conduction band
355 edge with increasing pressure, but underestimated the direct bandgap at the K point. Therefore, we
356 applied the HSE06 functional to correct the bandgap of monolayer MoSe₂, as shown in
357 Supplementary Fig. 7b. We found that the HSE06 functional corrected the bandgap at the K point as
358 1.99 eV for unstrained monolayer MoSe₂, which is close to the result (2.08 eV) from G_0W_0
359 calculations [13]. However, even for unstrained monolayer MoSe₂, the conduction band edge is at
360 the Λ point, which is inconsistent with our experimental observations. Thus, the HSE06 functional
361 failed to describe the Λ -K crossover of the conduction band edge with increasing pressure.

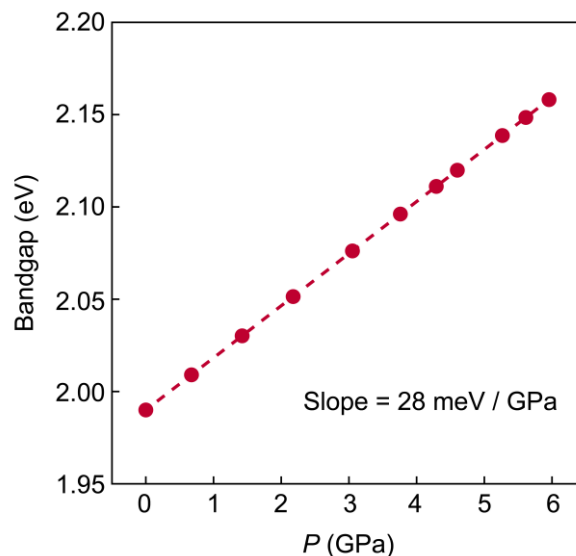
362 To avoid such inconsistency, as shown in Supplementary Fig. 8, we used the direct bandgap of the
363 unstrained monolayer MoSe₂ obtained from HSE06 calculations, but the change in the direct bandgap
364 with increasing pressure was calculated by using the GGA-PBE functional. As the pressure increases
365 from 0 to 6.0 GPa, the bandgap increases linearly from 1.99 to 2.16 eV with a slope equal to 28
366 meV/GPa. The increase in the bandgap directly leads to a blueshift of the exciton and trion emission
367 energies in the PL measurements. Note that the K valley of the conduction band in monolayer MoSe₂
368 moves upward with increasing pressure, whereas the Λ valley moves downward. As a direct result,
369 the conduction band minimum switches from the K valley to the Λ valley (Supplementary Fig. 7a).
370 This result directly demonstrates the Λ -K crossover in our pressurized monolayer MoSe₂.

371 To confirm that our DFT calculation results can describe the real band structure change of the
372 monolayer TMDCs sample under pressure, we systematically compare our calculation results under
373 hydrostatic pressure and the results from previous theoretical report of MoS₂ samples under out-of-
374 plane uniaxial pressure [37]. Generally, when the sample undergoes out-of-plane uniaxial pressure,
375 the K valley moves downward with increasing pressure, whereas the Λ valley remains almost
376 unchanged. As a result, the sample maintains a direct bandgap transition under pressure with a lower
377 bandgap. This would expect to result in a redshift of exciton emission energy and increase of PL
378 intensities. In sharp contrast, in our experiments, the exciton emission energy shows clear blueshift
379 and the PL intensity decrease with increasing pressure, showing a typical Λ -K crossover at 3.0 GPa.
380 Such a result can only be well-explained by our DFT calculation with sample under hydrostatic
381 pressure.



382

383 **Supplementary Figure 7. a**, Calculated band structures of monolayer MoSe₂ with the GGA-PBE functional
 384 under different pressures in the 0.0 ~ 6.0 GPa range. The zero in the energy axis is set at the Fermi level, as
 385 shown by the purple dashed line. The pressure is calculated within the GGA-PBE functional. **b**, The calculated
 386 band structures of unstrained monolayer MoSe₂ with the HSE06 functional. The zero in the energy axis is set
 387 at the Fermi level, as shown by the purple dashed line.



388

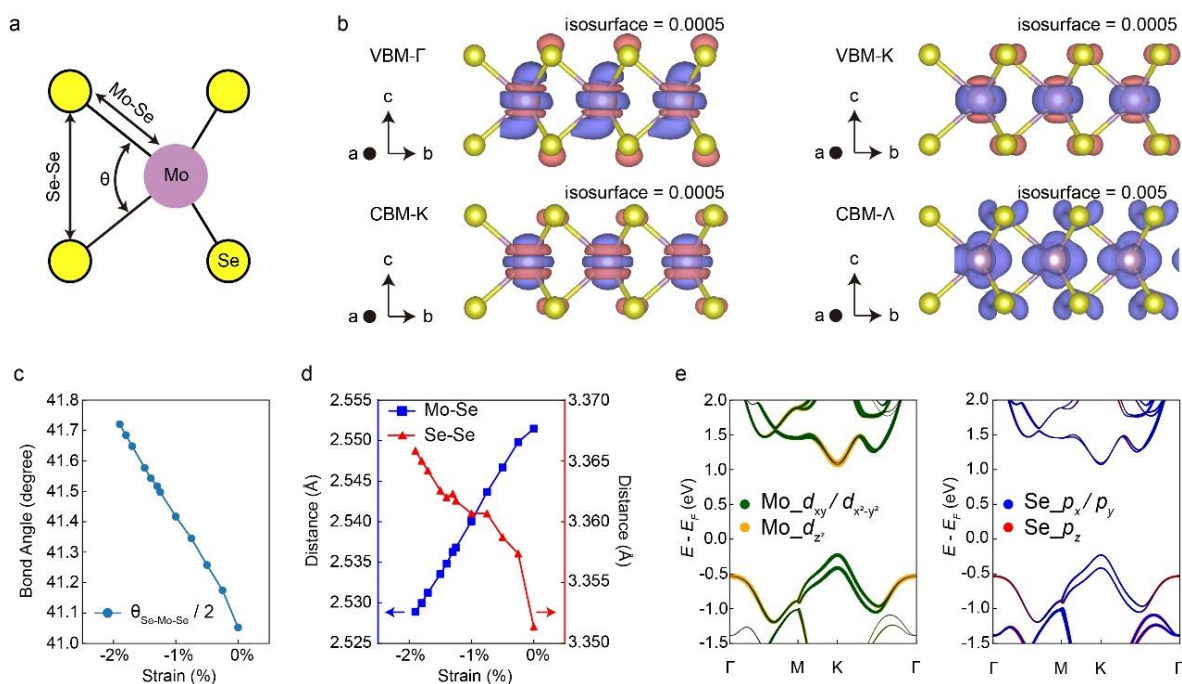
389 **Supplementary Figure 8.** The change in bandgap as a function of pressure obtained from DFT calculations.
 390 The HSE06 functional is used to obtain the bandgap of the unstrained monolayer MoSe₂ and bandgap changes
 391 with increasing pressure are obtained from GGA-PBE functionals. The red dashed line is a linear fitting of data
 392 with a slope equals to 28 meV/GPa.

393 To further clarify how pressure modulate the band structures of monolayer MoSe₂, we performed
 394 DFT to calculate the lattice structures and electronic structures for MoSe₂ with and without pressure.
 395 As shown in Supplementary Fig. 9b,e, the valence band maximum at Γ point (VBM- Γ) and the
 396 conduction band minimum at the K point (CBM-K) in MoSe₂ are mainly contributed by the d_{z^2}

397 orbital of Mo atoms and p_x/p_y orbitals of Se atoms. Meanwhile, the valence band maximum at K
 398 point (VBM-K) and the conduction band minimum at Λ point (CBM- Λ) are dominated by the d_{xy}
 399 and $d_{x^2-y^2}$ orbitals of Mo atoms and p_x/p_y orbitals of Se atoms. The energy positions of these states
 400 around the Fermi level are determined by the couplings between d orbitals of Mo atoms and p orbitals
 401 of Se atoms, which are sensitive to the bond angle and the distances between Mo and Se atoms.

402 With increasing pressure, the bond angle ($\theta = \angle_{\text{Se-Mo-Se}}$ as shown in Supplementary Fig. 9a) and
 403 the distance between Se and Se atoms increase, while the distance between Se and Mo atoms
 404 decreases (Supplementary Fig. 9c-d). As a result, the overlap between d_{z^2} orbital (Mo) and p_x/p_y
 405 orbitals (Se) becomes larger while the overlap between $d_{xy}/d_{x^2-y^2}$ orbitals (Mo) and p orbitals (Se)
 406 becomes smaller. Correspondingly, the energy splitting between the VBM- Γ and CBM-K becomes
 407 larger while that between the VBM-K and CBM- Λ becomes smaller, which causes the increase of
 408 the band gap at the K point and the related Λ -K crossover for conduction bands. Our calculated results
 409 are consistent with previous discussions for pressured MoS₂ [38, 39].

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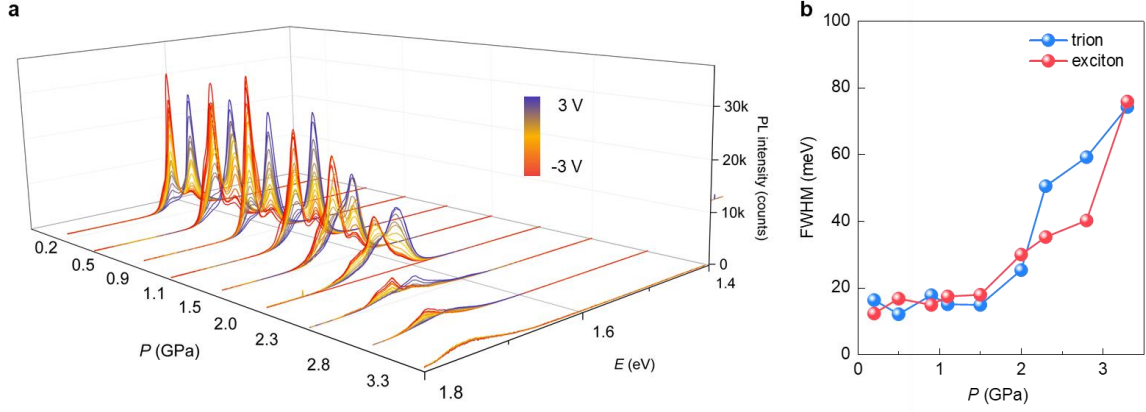
412 **Supplementary Figure 9. Illustration of the Λ -K crossover of conduction bands.** **a**, The illustration of the
 413 structure of the MoSe₂ monolayer. **b**, The visualization of the partial charge density at VBM- Γ , VBM-K, CBM-
 414 K, and CBM- Λ for monolayer MoSe₂. The Software, VESTA, is used for visualization [40]. **c-d**, The illustration
 415 of the variation of the bond angle and the distances between specified atoms along with the applied compressive
 416 pressure. **e**, The band structure of the unstrained MoSe₂ monolayer.

417

418 **VI. Gate-dependent PL spectra of *h*BN-gated monolayer MoSe₂ devices at various pressures**

419 As mentioned in Fig. 2 in the main text, by applying gate bias (V_G) to change the concentration of
420 electrons, we can control the dominant exciton species (exciton or trion) in MoSe₂ under pressure.
421 Here, in Supplementary Fig. 10a, we show more details of the gate-dependent PL spectra of
422 monolayer MoSe₂ at various pressures from 0.2 GPa to 3.3 GPa. Supplementary Figure 10b shows
423 that the FWHM of the exciton and trion peaks increase with pressures from 0.2 GPa to 3.3 GPa. The
424 reason for the increased FWHM is the pressure-induced indirect band-gap optical transition in the
425 band structure of monolayer MoSe₂. As mentioned in Fig. 1 of the main text, there are two types of
426 excitons corresponding to the direct and indirect bandgap transitions in monolayer MoSe₂ under
427 pressure, in which the direct bandgap transition does not need to involve phonons, while the indirect
428 bandgap transition needs to involve phonons. And the PL emission of monolayer MoSe₂ will contain
429 both direct and indirect excitons at higher pressures. With increasing pressure, the ratio between these
430 two types of excitons changes, and the excitons corresponding to the indirect bandgap transition
431 become dominant with more phonons being involved in the optical transition process. As a result,
432 one can observe the broadening of the PL spectra. Note that the non-hydrostatic component of the
433 pressure at low temperature in our case and its contribution for PL broadening are very small.
434 Specifically, it has been confirmed that the linewidth of the ruby peaks at low temperatures changes
435 little with pressure below 5 GPa, which means even at low temperature the sample should undergo
436 quite good hydrostatic pressure [41]. Therefore, we believe the peak broadening under pressures
437 mainly originates from the emergence of a direct-indirect bandgap transition (the so-called Λ -K
438 crossover).

439 Note that the exciton and trion emission energies increase slowly with pressure below 2.0 GPa and
440 start to quickly increase with a sudden change in exciton and trion emission energy under the pressure
441 over 2.0 GPa (details in Fig. 3b in main text). Such behavior is slightly different from the theoretical
442 prediction, where the exciton and trion emission energies increase linearly with increasing pressure.
443 We believe the reason for the sudden change in exciton and trion emission energy is that, below 2.0
444 GPa, the pressure in the sample at 77 K is partially released with temperature cooling while the
445 pressure is estimated by ruby PL spectra at 300 K. Specifically, when the pressure is determined at
446 room temperature and the DAC is cooled to 77 K, the pressure usually changes somewhat due to the
447 thermal contraction of the DAC, etc. The difference in the pressure values at room and low
448 temperatures is rather nonmonotonic and unpredictable, which results in the uncertainty in the
449 nominal pressure values. As a result, one may observe that the exciton/trion energy changes slowly
450 with pressure below 2.0 GPa and starts to change quickly above 2.0 GPa. Fortunately, both the
451 experiments and theoretical prediction yield a total blueshift of ~ 55 meV in exciton and trion
452 emission energy from 0 to 2.3 GPa. Therefore, the sudden jump will not influence our conclusion
453 that exciton and trion emission energies show dramatic blueshift with increasing pressure and will
454 not affect the estimation of trion binding energy values under different pressures.



455

456 **Supplementary Figure 10. Gate-dependent PL spectra at various pressures.** **a**, Gate-dependent PL spectra
 457 at various pressures. The data are obtained at a fixed temperature of 77 K at 0.2, 0.5, 0.9, 1.1, 1.5, 2.0, 2.3, 2.8
 458 and 3.3 GPa. The gate bias is applied from -3 V (red curve) to 3 V (blue curve). The PL spectra obtained at
 459 different pressures are shifted for better visualization. **b**, Full width at half maximum (FWHM) of the exciton
 460 (red balls) and trion (blue balls) peaks as a function of pressure.

461 To understand the exciton-to-trion transition under pressure, we present the colored mapping for the
 462 sum of the integrated area of trion and exciton PL peaks ($I_{\text{total}} = I_{\text{trion}} + I_{\text{exciton}}$) and the color
 463 mapping for the weight of the integrated area of the trion PL peak (denoted as $I_{\text{trion}}/I_{\text{total}}$) in Fig.
 464 2i,j in the main text. Here, in Supplementary Fig. 11, we show all the original data of excitons, trions,
 465 and their total integrated area of PL peaks as a function of V_G at various pressures. One can see that
 466 the I_{total} values change slightly before 2.0 GPa and start to drop quickly with increasing pressure
 467 after 2.0 GPa and eventually decrease to a very low level at 3.3 GPa, which directly corresponds to
 468 the Λ -K crossover with increasing pressure. Such pressure-dependent PL emission intensities can be
 469 understood as follows: first, for pressures below 2.0 GPa, all the PL emissions come from the direct
 470 K-K transition and therefore change little with increasing pressure; second, for pressures from 2.0 to
 471 2.8 GPa, the indirect Λ -K transition starts to be involved; therefore, the PL emissions drop quickly
 472 in this pressure regime. Third, for pressures above 2.8 GPa, all the PL emissions come from the
 473 indirect Λ -K transition, so the total PL emission intensities decrease to a very low level. Notably,
 474 the gate-controlled exciton-to-trion transition can be realized in monolayer MoSe₂ below 2.8 GPa,
 475 while no apparent gate response of PL emissions is observed at 3.3 GPa (Supplementary Fig. 10a).
 476 This result directly confirms that the sample has completely changed to an indirect bandgap
 477 semiconductor after 2.8 GPa; hence the exciton and trion from the direct transition are no longer
 478 observed.

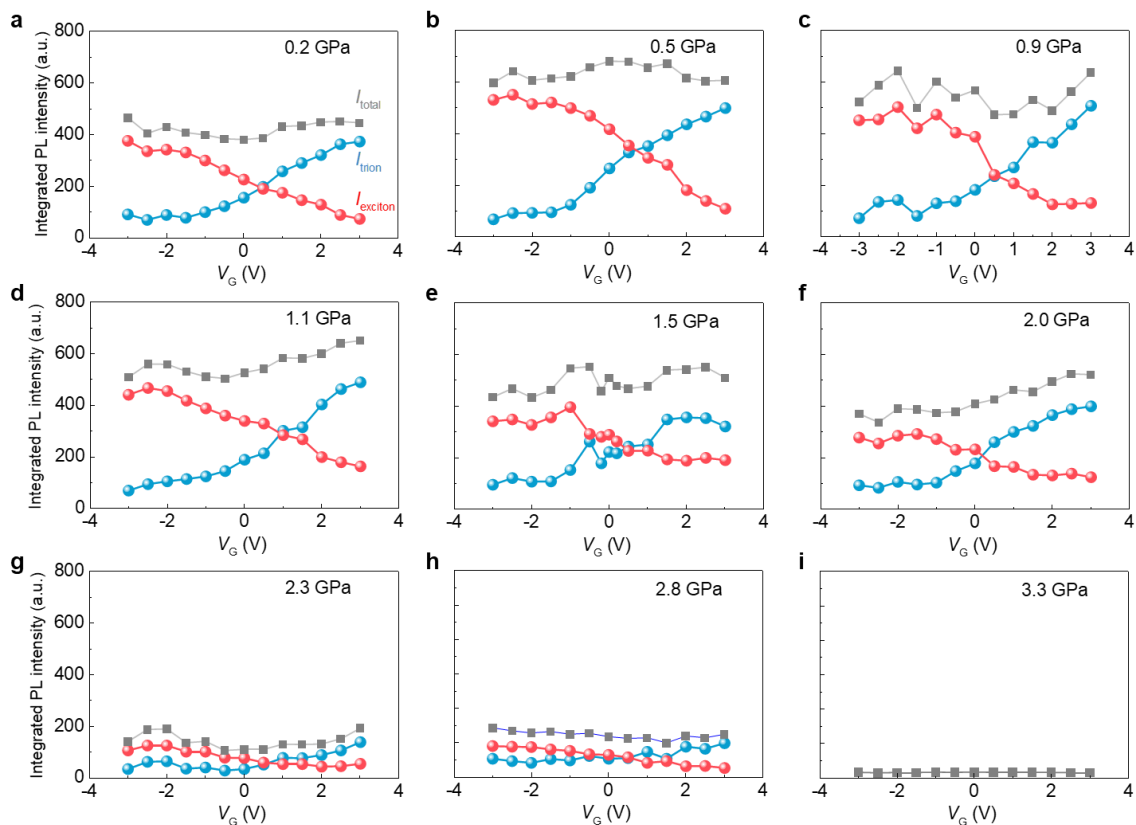
479 We also estimate the two-dimensional carrier density (n_{2D}) in monolayer MoSe₂ in the above gating
 480 process, by considering the Au/*h*-BN/MoSe₂ sandwiched device as a parallel plate capacitor. The
 481 amount of charge per unit area can be written as:

$$482 \quad en_{2D} = \epsilon_0 \epsilon_r / d \times (V_G - V_{\text{th}})$$

483 where e is the electron charge, ϵ_0 is the vacuum permittivity, $d = 20$ nm and $\epsilon_r = 4$ are the thickness
 484 and the relative dielectric constant of *h*-BN, respectively, and $V_{\text{th}} \approx -2$ V is the threshold voltage that

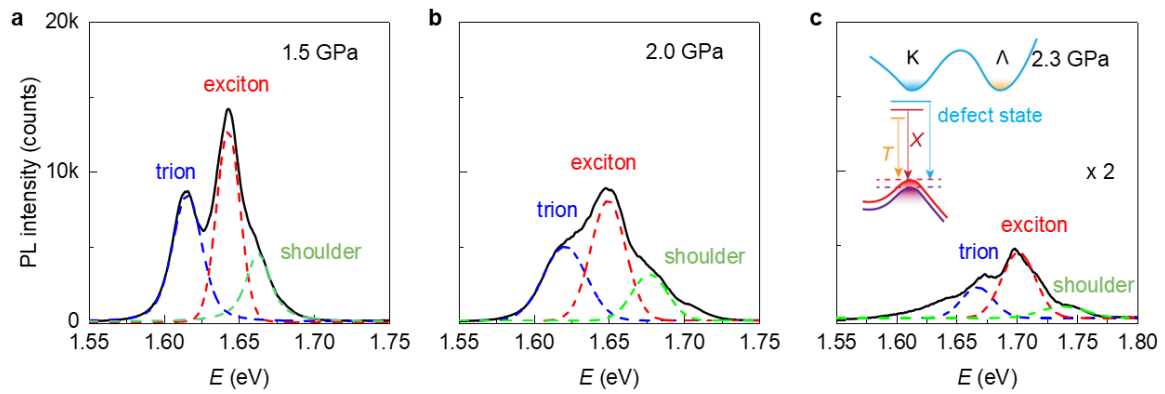
485 corresponds to the charge neutrality point of the sample (Supplementary Fig. 11a). Based on the
 486 above equation, we actually modulate the monolayer MoSe₂ sample from near neutrality to an
 487 electron density of approximately $5 (\pm 1) \times 10^{12} \text{ cm}^{-2}$ when increasing V_G from -3 to 3 V.

488 In the pressure-dependent PL spectra of monolayer MoSe₂, one can see a shoulder on the higher
 489 energy side of the exciton peak for PL spectra at higher pressures (Supplementary Fig. 12). This
 490 higher energy peak might result from the newly-generated defect states under pressure in monolayer
 491 MoSe₂, as shown in Supplementary Fig. 12c. For example, it has been reported recently that defects
 492 in MoSe₂ such as Se atom vacancies can generate defect states in the energy gap [42-45]. The energy
 493 level of these defects can be either higher or lower than the exciton energy. These defect states with
 494 higher energy may appear under pressure and can show blueshift with increasing pressure due to the
 495 direct bandgap increasing, which is consistent with the blueshift of the higher energy peak with
 496 pressure in our experiment. Since the focus of this paper is to demonstrate the robust trion binding
 497 energy, which is only related to the exciton and trion emission energy under pressure, we believe the
 498 shoulder on the higher energy side of the exciton peak would not affect our conclusions. The study
 499 of this higher energy peak under pressure can be an interesting research topic in near future.



500
 501 **Supplementary Figure 11. Gate-tuned exciton-trion transition under various pressures. a-i,** Exciton (red
 502 balls), trion (blue balls), and total (gray squares) integrated PL intensities as functions of V_G at different
 503 pressures. Note that at 3.3 GPa, the gate-controllable exciton-to-trion transition is not observed because the
 504 sample changes from a direct bandgap to an indirect bandgap, and all the PL emissions come from the indirect
 505 transition. The integrated PL intensities are obtained by fitting the PL spectra with multiple Voigt functions.

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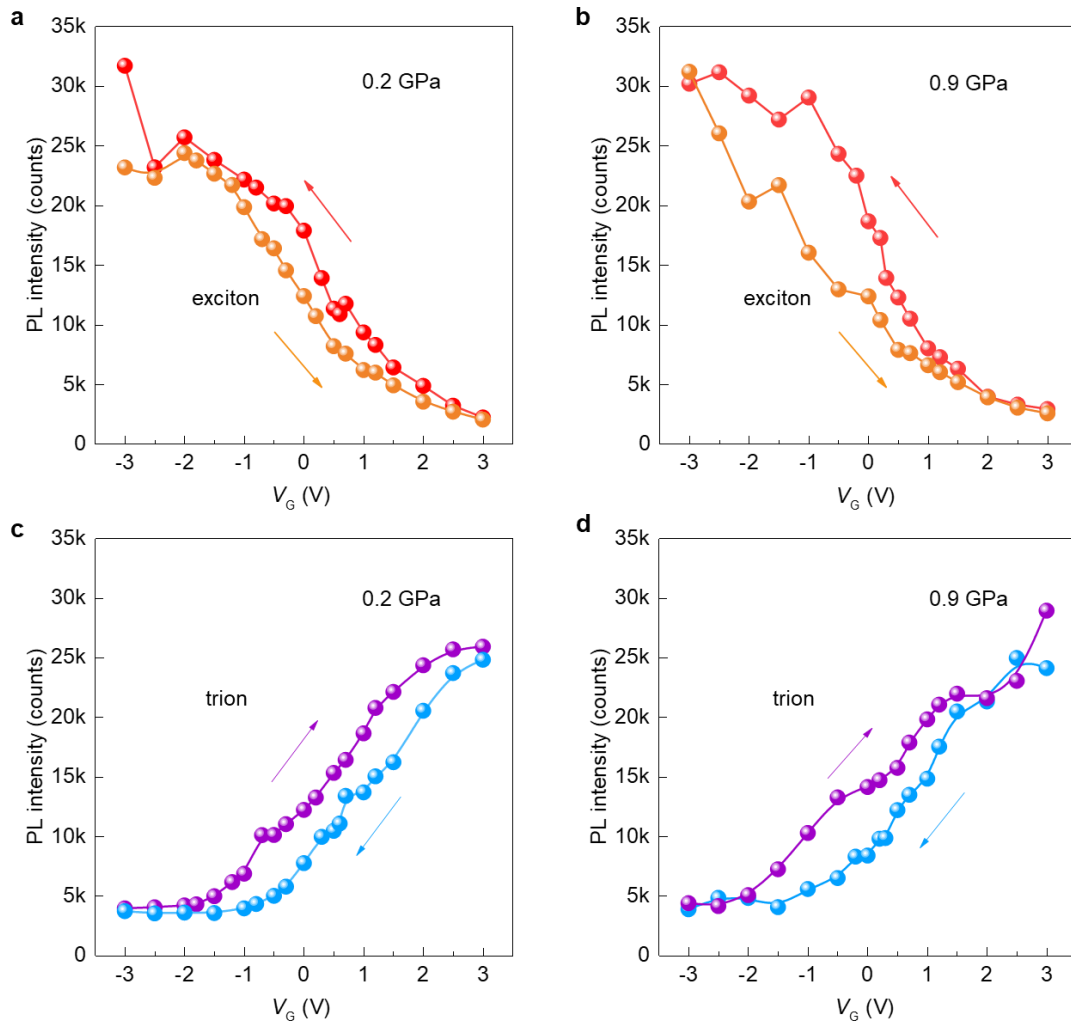
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Supplementary Figure 12. Origin of the higher energy peak in monolayer MoSe₂ under pressure. a-c, PL spectra of monolayer MoSe₂ at zero gate bias under 1.5 GPa (a), 2.0 GPa (b), and 2.3 GPa (c). The red and orange dashed curves represent the fitting of the exciton and trion peaks. The green dashed curves represent the fitting of the higher energy peak. Inset: Schematics of the band structure of monolayer MoSe₂ under pressure. The red and orange arrows represent the recombination of excitons and trions. The blue arrows represent the recombination of a higher energy defect state.

514 **VII. Precise determination of the exciton and trion emission energy under pressure using**
 515 ***gating-under-pressure* technique**

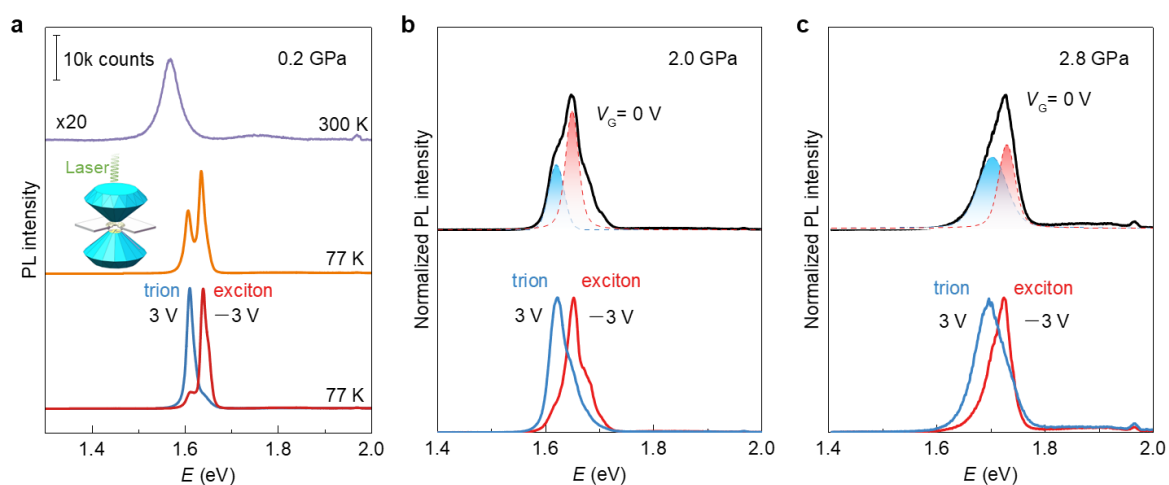
516 To highlight the reversibility of the gate-tuned exciton-trion transition in pressurized monolayer
 517 MoSe₂, we provide the PL intensities of excitons and trions at gate sweep cycles ranging from -3 V
 518 to 3 V in Supplementary Fig. 13. Both the PL intensities of the exciton and trion almost return to
 519 their initial values after the gate-sweeping loop, indicating that the process is reversible in the bias
 520 range of -3 V to 3 V. Furthermore, such a reversible gating process is independent of the external
 521 pressure, as shown in Supplementary Fig. 13b,d (0.2 and 0.9 GPa, respectively). Note that the PL
 522 intensity as a function of V_G exhibits a small hysteresis, which is quite common in those cases in *h*-
 523 BN or EDL gate devices [46].



524 **Supplementary Figure 13. Reversible gate-tuned exciton-trion transition under pressure.** PL intensity of
 525 exciton as a function of gate bias, obtained at **a**, 0.2 GPa and **b**, 0.9 GPa. The orange (or red) balls represent
 526 data obtained by applying V_G from -3 V to 3 V (3 V to -3 V). PL intensity of trion as a function of gate bias,
 527 obtained at **c**, 0.2 GPa and **d**, 0.9 GPa. The purple (or blue) balls represent data obtained by applying V_G from
 528 -3 V to 3 V (3 V to -3 V). The data are obtained at 77 K.

529 To highlight the technical advance of our *gating-under-pressure* technique at low temperature for
 530 simultaneously observing excitons and trions under pressure, we compare the PL spectra of

531 monolayer MoSe₂ at 300 K, 77 K, and 77 K with gating. As shown in Supplementary Fig. 14a, after
 532 lowering the temperature to 77 K, the FWHM of the exciton peak becomes relatively narrow (from
 533 51 meV to 12 meV), and the PL intensity is magnified over 20 times larger than its original value at
 534 300 K. More importantly, as shown in the bottom panel in Supplementary Fig. 14a, by applying a
 535 ± 3.0 V back gate voltage (V_G) to electrically tune the electron concentration in MoSe₂, exciton and
 536 trion emission peaks can be distinguished in the spectra and switched between exciton-dominated
 537 and trion-dominated states. Such electrical control of exciton and trion states is vital to studying
 538 excitonic physics under pressure. As shown in Supplementary Fig. 14b,c, at 2.0 GPa or 2.8 GPa, it
 539 is difficult to distinguish excitons and trions at $V_G = 0$ V due to the peak broadening induced by
 540 pressure, and a tricky fitting of PL spectra is required to obtain the exciton and trion emission energies.
 541 However, since we have demonstrated that our fully reversible gate process (Supplementary Fig. 13)
 542 could dramatically tune the PL intensity of excitons and trions without changing their emission energy
 543 (Fig. 3a in the main text), we can directly determine the emission energy of excitons (or trions)
 544 by analyzing the PL spectra at $V_G = -3$ V (or 3 V), as shown in Supplementary Fig. 14b,c. Therefore,
 545 by applying electrical gating within DAC at low temperature, our *gating-under-pressure* technique
 546 provides opportunities to study excitonic behavior and many-body effects under pressure. To the best
 547 of our knowledge, this work is the first demonstration of gate-controlled trion (and exciton) states in
 548 monolayer TMDCs under high pressure via a gating-under-pressure technique (Table S1), which can
 549 indeed effectively tune the band structure of TMDCs and the trion (and exciton) states therein.



550
 551 **Supplementary Figure 14. Gate-under-pressure technique for exciton and trion states of monolayer**
 552 **MoSe₂ determination under pressure.** **a**, A direct comparison of the PL spectra of monolayer MoSe₂ obtained
 553 at 300 K (purple curve), 77 K (orange curve), and 77 K with a back gate bias of ± 3 V (red and blue curves).
 554 The PL spectra obtained at 300 K are magnified 20 times. All the PL spectra are shifted on the Y-axis for better
 555 visualization. The inset is a schematic figure for high-pressure DAC setup. A direct comparison of the PL
 556 spectra of monolayer MoSe₂ with and without a gate at 2.0 GPa, **b**, or 2.8 GPa, **c**. The red, black, blue plots
 557 represent the PL spectra obtained at $V_G = -3, 0, 3$ V. The PL spectra at $V_G = 0$ V are shifted on the Y-axis for
 558 better visualization. The red and blue dashed plots are fitting results for exciton and trion peaks by the multiple
 559 Voigt functions. All PL spectra were obtained at 77 K.

560

Table S1: A summary of the study of pressurized monolayer TMDCs

Material	Theoretical		Experimental				Refs.
	Methods	Results	Methods	E_{exciton}	E_{trion}	Temperature	
MoSe₂	DFT, QMC	E_g E_{exciton} E_{trion}	Gated PL	Yes	Yes	300 K 77 K	This work
MoS ₂	DFT	E_g	NA	Yes	NA	NA	[38]
MoS ₂	DFT	E_g	NA	Yes	NA	NA	[47]
MoS ₂	DFT	E_g	PL no gate	Yes	NA	300 K	[48]
MoS ₂	DFT	E_g	PL no gate	Yes	NA	300 K	[39]
MoS ₂	DFT	E_g	PL no gate	Yes	NA	300 K	[49]
MoS ₂ , MoSe ₂ , WS ₂ , WSe ₂	DFT	E_g	Reflectance no gate	Yes	NA	300 K	[50]
WSe ₂	DFT	E_g	PL no gate	Yes	NA	300 K	[51]
MoSe ₂	DFT	E_g	PL no gate	Yes	NA	300 K	[52]
MoSe ₂	DFT	E_g	PL no gate	Yes	NA	300 K	[53]

562 NA: not applicable.

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